

Journal of Organometallic Chemistry 488 (1995) 155-160



The geometry of SiOCN and SiNCO linkages. The crystal structures of $(Me_3Si)_2(Ph_2MeSi)CSiMe_2OCN$ and $(PhMe_2Si)_3CSiMe_2NCO^*$

Salih S. Al-Juaid, Ahmed A.K. Al-Nasr, G. Adefikayo Ayoko, Colin Eaborn *, Peter Hitchcock

School of Chemistry and Molecular Sciences, University of Sussex, Brighton BN1 9QJ, UK

Received 16 June 1994

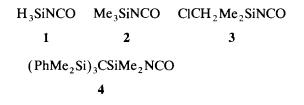
Abstract

Single crystal X-ray diffraction studies have been carried out on the title compounds (in the case of the cyanate as its methylcyclohexane solvate). The geometry of the SiNCO fragment in the isocyanate (PhMe₂Si)₂CSiMe₂NCO (\angle SiNC = 155.7(5), \angle NCO = 175.9(7)°, d(Si-N) = 1.739(5), d(N-C) = 1.135(8), d(C-O) 1.174(8) Å) is very similar to that in the much less crowded compounds H₃SiNCO and ClCH₂Me₂SiNCO, but in all three compounds the Si-N-C angle is a little smaller than in Me₃SiNCO. In the light of the results the validity of recent calculations indicating an Si-N-C angle of 180° in H₃SiNCO is questioned. In the case of the cyanate (Me₃Si)₂(Ph₂MeSi)CSiMe₂OCN, disorder results in considerable uncertainty in the geometry of the SiOCN linkage, but the values for the O-C-N and Si-O-C angles, 175(1)° and ca. 124 ± 6°, respectively, are consistent with those predicted by the corresponding calculations on H₃SiOCN.

Keywords: Silicon; Cyanate; Isocyanate; Crystal structure

1. Introduction

Crystal structure data for silicon isocyanates have previously been available for H_3SiNCO , 1, (determined at $-133^{\circ}C$ [1], Me₃SiNCO, 2 (at $-90^{\circ}C$) [2], and ClCH₂Me₂SiNCO, 3, at ($-90^{\circ}C$) [3]. In all three cases the NCO linkage was found to be close to linear. A significant difference between the value of the Si-N-O angle in 2 (163.6(6)°) and that in 3 (158.3(2)°) was attributed to crystal packing effects arising from the bulk of the chlorine atom in 3 [3]. We thought it of interest to determine the structure of the compound (PhMe₂Si)₃CSiMe₂NCO, 4, in order to see whether the very bulky (PhMe₂Si)₃C group would have any significant effect on the geometry of the SiNCO linkage. Added interest was provided by the results of recent calculations by Fehér and his colleagues [4] that pointed to an Si-N-C angle of 179.88° in 1 and led the authors to question the accuracy of a value of 159.84° derived earlier from microwave data [5].



In contrast, no structural data have previously been available for any silicon cyanate, the first example of which, viz. $(Me_3Si)_3CSiMe_2OCN$, was reported in 1982 [6], but the calculations by Fehér et al. on H₃SiOCN predicted an Si–O–C angle of 120.43° and an O–C–N angle of 178.43° [4]. We found that significant diffraction data could not be obtained for $(Me_3Si)_3CSiMe_2$ -OCN, probably because the spherical nature of the molecule gives rise to plastic crystal behaviour, as is the case for $(Me_3Si)_4C$ at room temperature. We were, however, able to obtain data for $(Me_3Si)_2(Ph_2MeSi)$ -CSiMe₂OCN, **5**, (as its methylcyclohexane solvate) though they are badly affected by disorder in the crystal.

^a Dedicated to Professor Fausto Calderazzo on the occasion of his 65th birthday in recognition of his important contributions to organometallic and inorganic chemistry.

^{*} Corresponding author.

⁰⁰²²⁻³²⁸X/95/\$09.50 @ 1995 Elsevier Science S.A. All rights reserved SSDI 0022-328X(94)00014-X

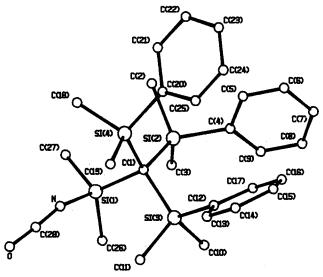


Fig. 1. Molecular structure of 4, with atom numbering scheme.

2. Results and discussion

The molecular structure of 4 is shown in Fig. 1, and selected bond lengths and angles are listed in Table 1. There were no significant intermolecular contacts. (In contrast, in the case of 3 there are short $C \cdots O$ contacts.)

Table 1

Selected intramolecular distances (Å) and angles (°) in 4 with estimated standard deviations in parentheses

(a) Bonds			
Si(1)-N	1.739(5)	Si(1)-C(1)	1.902(5)
Si(1)-C(26)	1.871(6)	Si(1)-C(27)	1.864(7)
Si(2)–C(1)	1.938(5)	Si(2)-C(2)	1.876(5)
Si(2)-C(3)	1.886(6)	Si(2)-C(4)	1.895(5)
Si(3)-C(1)	1.942(5)	Si(3)-C(10)	1.879(6)
Si(3)-C(11)	1.878(6)	Si(3)-C(12)	1.900(6)
Si(4)-C(1)	1.937(5)	Si(4)C(18)	1.877(6)
Si(4)-C(19)	1.876(6)	Si(4)-C(20)	1.880(5)
O-C(28)	1.174(8)	N-C(28)	1.135(8)
(b) Angles			
N-Si(1)-C(1)	108.3(2)	N-Si(1)-C(26)	104.4(3)
N-Si(1)-C(27)	103.0(3)	C(1)-Si(1)-C(26)	116.9(3)
C(1)-Si(1)-C(27)	117.5(2)	C(26) - Si(1) - C(27)	105.2(3)
C(1)-Si(2)-C(2)	112.8(2)	C(1) - Si(2) - C(3)	112.8(2)
C(1) - Si(2) - C(4)	116.3(2)	C(2) - Si(2) - C(3)	104.7(3)
C(2) - Si(2) - C(4)	104.6(2)	C(3) - Si(2) - C(4)	104.6(2)
C(1)-Si(3)-C(10)	112.4(2)	C(1) - Si(3) - C(11)	112.1(2)
C(1) - Si(3) - C(12)	115.6(2)	C(10) - Si(3) - C(11)	106.0(3)
C(10) - Si(3) - C(12)	105.1(3)	C(11) - Si(3) - C(12)	104.9(3)
C(1)-Si(4)-C(18)	112.9(2)	C(1) - Si(4) - C(19)	112.9(2)
C(1) - Si(4) - C(20)	115.6(2)	C(18) - Si(4) - C(19)	104.9(2)
C(18) - Si(4) - C(20)	104.7(2)	C(19) - Si(4) - C(20)	104.8(2)
Si(1)-N-C(28)	155.7(5)	Si(1)-C(1)-Si(2)	105.8(2)
Si(1)-C(1)-Si(3)	107.1(2)	Si(1)-C(1)-Si(4)	106.9(2)
Si(2) - C(1) - Si(3)	112.3(2)	Si(2) - C(1) - Si(4)	112.3(2)
Si(3) - C(1) - Si(4)	112.0(2)	Si(2)-C(4)-C(5)	120.5(4)
Si(2)C(4)-C(9)	122.4(4)	O-C(28)-N	175.9(7)

Table 2	
---------	--

Bond	lengths	(Å)	and	angles	(°)	found	for	the	SiNCO	linkage	in
compo	ounds 1,	3 an	d 4,	and (1	calc	.) calcu	ilate	d [5]	for that	t in 1	

	4	3	1	1 calc.
Si-N	1.739(5)	1.731(2)	1.723(4)	1.719
N-C	1.135(8)	1.176(2)	1.181(5)	1.205
С-О	1.174(8)	1.173(2)	1.168(5)	1.187
SiNC	155.7(5)	158.3(5)	158.2(3)	179.88
NCO	175.9(7)	177.6(3)	176.2(5)	179.99

In Table 2 the more significant bonding parameters for the SiNCO system in 4 are shown alongside those in 1 and 3; data for 2 are not included because, except in respect of the Si-N-C angle (see above), they are not significantly different from those for 3. Also shown are parameters determined for 1 from the microwave spectrum. There is remarkably little difference between the parameters derived for crystals of all three compounds; the N-C bond in 4 may perhaps be a little shorter than those in the other two, but the observed difference cannot be regarded as significant when account is taken of the estimated standard deviations, and seems unlikely to be real because the Si-N and C-O distances and the associated angles are so similar in all three compounds. Since there is so little difference overall between the data for the small molecule 1, the somewhat more crowded 3, and the much more crowded 4, the slightly larger Si-N-C angle in 2 appears to be somewhat anomalous, but it could be simply the result of a chance packing effect [3]. Since an Si-N-C angle in the region of 158° is found in all four crystal structures and one of 159.84° was derived for 1 from microwave data [5] it seems to us unlikely that the value of 180° recently calculated by Fehér and his colleagues for 1 [4] is valid, especially since an electron diffraction study indicated a value of 151.7° for this molecule [8].

The slight departure of the NCO linkage from linearity in the crystals of all four compounds 1-4 suggests that this is an intrinsic property of the linkage, but the value of 179.99° calculated for 1 [4] could be correct for the gas phase. The Me-Si-Me angle in the SiMe₂NCO system is much smaller for 4, viz. 105.2(3)°, than for 3, 113.5(1)°, presumably because the Me groups in 4 move together, away from the (PhMe₂Si)₃C group, to relieve the strain. Correspondingly the mean Me-Si-N angle in 4, 103.7(3)°, is much smaller than that in 3 (110.7(1)°).

There is some interest in the conformation adopted by the (PhMe₂Si)₃C group [9,10], which in **4** is similar to that in, e.g. (PhMe₂Si)₃CSiCl₃ [9], [{(PhMe₂Si)₃CHg-Cl)₂] [10], and (PhMe₂Si)₃CSnMe₂F [11]]; i.e. the three Ph groups are arranged in a propeller fashion (the dihedral angles between the plane of the Si(2), Si(3), and Si(4) atoms and the planes of the C(4)-C(9),

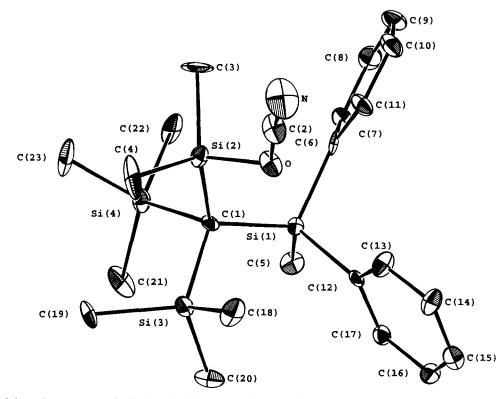


Fig. 2. Structure of the major component in the disordered crystal of 5. (MeC_6H_{11}), with atom numbering scheme. The atoms are shown as 20% thermal vibration ellipsoids.

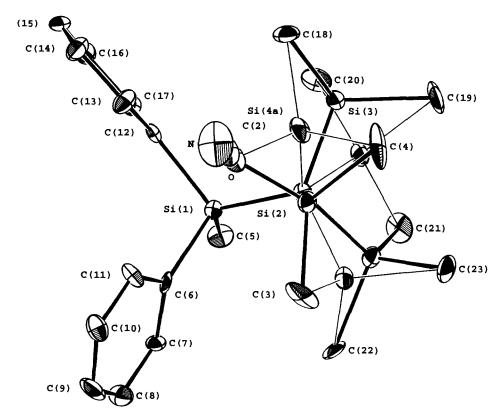


Fig. 3. Diagram showing the nature of the disorder in the crystal of 5. (MeC_6H_{11}) . The thick and thin lines indicate bonds in the major and minor component, respectively.

C(12)–C(17), and C(20)–C(25) rings are 85, 94, and 92°, respectively), with all three of the Ph groups pointing away from the fourth ligand on the central carbon, and an ortho-proton of one of the groups lying above the plane of the ring of another, a disposition that would be expected to show up in the ¹H NMR spectrum in solution at low temperature [9]. In contrast, in, e.g. (PhMe₂Si)₃CH [12] and (PhMe₂Si)₃CHgC{SiMe₃)₃} [13], two Ph groups lie away from the fourth ligand and one towards it, and one Me group of each SiMe₂Ph fragment lies above the plane of another Ph group, again with consequences for the low temperature ¹H NMR spectrum [9].

Other features of the geometry of the $(PhMe_2Si)_3C$ group are as usual. Thus, the C(1)-SiMe₂Ph bonds, mean 1.939(2) Å, are longer than the Si-Me, mean 1.879(3) Å, and Si-Ph bonds, mean 1.892(8) Å (and are also longer than the C-SiMe₂NCO bond, 1.902(5)°), and the C(1)-Si-Me angles, mean $112.6(3)^\circ$, are markedly larger than, and the Me-Si-Me angles, mean 105.2(3)°, markedly smaller than, the tetrahedral angle; the C(1)–Si–Ph angles, mean $115.8(4)^\circ$, are even larger. The Si-Me bond lengths in the SiMe₂NCO group, mean 1.868(6) Å, are not significantly different from those in the (PhMe₂Si)₃C group, but they are somewhat longer than those in 3, mean 1.843(5) Å. The N atom lies only 3.274(4) Å from Si(4), a distance appreciably below the sum, 3.65 Å, of the relevant van der Waals radii, but such short intramolecular contacts are common in compounds containing (Me₃Si)₃C, (PhMe₂-Si)₃C or a related group, and are thought to be a consequence of the crowding and not to reflect weak bonding interactions [14].

2.1. Structure of $(Me_3Si)_2(Ph_2MeSi)CSiMe_2OCN$. Me- C_6H_{11}

Unfortunately, severe disorder was encountered in the crystal of the cyanate and gave rise to such uncer-

Table 3 Selected bond lengths (Å) and angles (°) in $(Me_3Si)_2(Ph_2MeSi)CSi-Me_3OCN$, 5

(a) Bonds			
Si(1)-C(1)	1.921(10)	Si(1) - C(5)	1.842(12)
Si(1)-C(6)	1.882(11)	Si(1)-C(12)	1.899(11)
Si(2)-O	1.756(10)	O-C(2)	1.27(2)
N-C(2)	1.12(2)	O-Si(4a)	1.774(11)
(b) Angles			
C(1) - Si(1) - C(5)	111.5(5)	C(1) - Si(1) - C(6)	114.2(5)
C(1)-Si(1)-C(12)	114.0(4)	C(5) - Si(1) - C(6)	104.0(50)
C(5)-Si(1)-C(12)	105.2(5)	C(6) - Si(1) - C(12)	107.1(5)
Si(2)-O-C(2)	118.1(8)	O-C(2)-N	175(1)
Si(4a)-O-C(2)	130.2(8)		

Table 4	2
---------	---

Fractional atomic coordinates ($\times 10^4$) and equivalent isotropic thermal parameters (Å $\times 10^3$) for 4

mai parameters $(A \times 10^{-})$ for 4						
	x	у	z	$U_{\rm eq}^{\rm a}$		
Si(1)	8445.9(14)	460.9(8)	1173.6(6)	54(1)		
Si(2)	10685.9(13)	1196.7(8)	771.1(5)	42(1)		
Si(3)	9987.3(15)	1428.9(9)	1818.2(5)	50(1)		
Si(4)	8372.2(13)	2181.2(8)	1039.6(5)	41(1)		
0	5350(5)	446(3)	1835(2)	148(4)		
Ν	7062(4)	657(3)	1417(2)	69(3)		
C(1)	9401(4)	1346(3)	1202(2)	38(3)		
C(2)	10214(5)	1388(3)	174(2)	55(3)		
C(3)	11256(5)	198(3)	763(2)	65(4)		
C(4)	12076(4)	1793(3)	855(2)	43(3)		
C(5)	12099(4)	2537(3)	712(2)	49(3)		
C(6)	13105(5)	2978(3)	760(2)	65(4)		
C(7)	14118(5)	2687(4)	949(2)	80(4)		
C(8)	14141(5)	1942(4)	1088(2)	78(4)		
C(9)	13126(4)	1505(3)	1035(2)	60(3)		
C (10)	11276(6)	776(3)	1933(2)	69(4)		
C(11)	8802(6)	1185(4)	2244(2)	76(4)		
C(12)	10542(5)	2397(3)	1992(2)	53(3)		
C(13)	9875(6)	2856(4)	2279(2)	80(4)		
C(14)	10271(7)	3555(4)	2408(2)	105(5)		
C(15)	11393(7)	3813(4)	2265(2)	103(5)		
C(16)	12092(6)	3362(4)	1997(2)	78(4)		
C(17)	11688(5)	2657(3)	1868(2)	59(3)		
C(18)	7268(5)	1935(3)	585(2)	61(3)		
C(19)	7434(5)	2524(3)	1524(2)	57(3)		
C(20)	9162(4)	3044(3)	824(2)	44(3)		
C(21)	9152(5)	3226(3)	355(2)	55(3)		
C(22)	9745(6)	3855(3)	191(2)	70(4)		
C(23)	10334(6)	4333(3)	484(2)	79(4)		
C(24)	10315(5)	4188(3)	945(2)	69(4)		
C(25)	9730(5)	3561(3)	1107(2)	54(3)		
C(26)	9004(6)	- 381(3)	1489(2)	88(5)		
C(27)	8035(6)	102(3)	602(2)	76(4)		
C(28)	6238(6)	537(3)	1630(2)	71(4)		

^a U_{eq} is defined as one third of the trace of the orthogonalised U_{ij} tensor.

tainty in the geometry of the SiOCN fragment that we publish the results simply because they provide the only structural data for any silicon cyanate. The disorder involved alternative sites for Si(2), Si(3) and Si(4) in a 55/45 occupancy ratio, with the two alternative sets of Si sites sharing overlapping Me and OCN sites that are unresolvable (see Figs. 2 and 3). From the parameters listed in Table 3 it can be seen that the O-C-N angle (which is not directly affected by the disorder) is 175(1)° and the Si-O-C angle can be estimated to be $124 \pm 6^{\circ}$, both values being consistent with those (178.4 and 120.4°, respectively) calculated for H₃SiOCN [4]. Certainly there is no doubt that the Si-O-C angle in the cyanate is much smaller than the Si-N-O angle in the various isocyanates. The observed approximate lengths of the O-C and C-N bonds, 1.27(2) and 1.12(2) Å, respectively, are also consistent with those, 1.330 and 1.185 Å, calculated for H₃SiOCN.

Table 6

The geometry of the OCN group in 5 is remarkably similar to that in a representative aryl cyanate, 4-chloro-3,5-dimethylphenyl cyanate, for which the relevant bond lengths and angles are as follows: d(O-C)

Table 5	
Crystal structure determination detail	ls for $5 \cdot MeC_6H_{11}$
Crystal data	
Formula	C27 H36N OSi4
Formula weight	508.9
Crystal system	orthorhombic
Space group	$P2_{1}2_{1}2_{1}$ (No. 19)
a (Å)	9.726(4)
b (Å)	16.010(6)
c (Å)	20.913(7)
Alpha (°)	90
Beta (°)	90
Gamma (°)	90
Cell volume (Å ³)	3256(2)
Z	4
D_{calc} (g cm ⁻³)	1.04
F(000)	1100
Monochromated Mo K α radiation	1100
λ (Å)	0.71073
μ (cm ⁻¹)	1.9
Temperature	173 K
Data collection	
Crystal size (mm ³)	Cut to $0.3 \times 0.3 \times 0.2$
Diffractometer	Enraf-Nonius CAD4
Reflections for calculating cell	
Number, θ min, θ max	25, 7, 10
Scan mode for data collection	$\theta - 2\theta$
Data reflection ranges,	$h \ 0 \rightarrow 12, \ k \ 0 \rightarrow 21,$
θ min and max (°)	$l 0 \rightarrow 27; 2 \rightarrow 28$
Total unique reflections measured	4402
Significant reflections, $ F^2 > 2\sigma(F^2)$	2332
F > 20(F) Max change in standard reflections	+7.4%
Decay correction	Yes
Empirical absorption correction,	No
$T_{\rm max}, T_{\rm min}$	140
* max * * min	
Structure solution and refinement	
Non-H atoms located by	direct methods sHELXS-86
Refinement by	Full matrix least squares
	non-H atoms anisotropic
	Enraf-Nonius MolEN
	programs
Hydrogen atoms	for H's on Si(1) only
	fixed calculated positions
	$U_{\rm iso} = 1.3 U_{\rm eq}$ for parent
7	atom
R	0.104
<i>R</i> ′	0.111
S No voziablas	1.3
No. variables	352
No. observed reflections $(A, (a))$ may	2332
$(\Delta/\sigma) \max$	0.6
$(\Delta \rho)$ max, min (e Å ⁻³)	+0.52, -0.22

 $\overline{\sigma(F^2) = \{\sigma^2(I) + (0.04I)^2\}^{1/2}/L_p}, \quad w = \sigma^{-2}(F), \quad \Sigma w(|F_o| - |F_c|)^2$ minimised.

Fractional atomic coordinates and equivalent isotropic thermal parameters for ${\bf 5}$

rameters for 5							
	x	у	z	U _{eq} ^a			
Si(1)	0.0606(3)	0.8186(2)	0.0869(1)	0.027(1)			
Si(2)	0.0849(7)	0.9624(4)	0.1934(3)	0.038(3)			
Si(3)	-0.0828(6)	0.8032(4)	0.2249(3)	0.037(3)			
Si(4)	-0.1873(7)	0.9382(4)	0.1282(3)	0.041(3)			
0	0.2462(8)	0.9148(5)	0.2030(3)	0.050(5)			
N	0.4274(12)	0.9870(9)	0.2573(6)	0.111(9)			
C(1)	-0.0247(10)	0.8775(6)	0.1563(5)	0.027(5)			
C(2)	0.3392(14)	0.9549(9)	0.2330(5)	0.059(8)			
C(3)	0.1116(17)	1.0593(7)	0.1406(6)	0.082(9)			
C(4)	0.0402(14)	0.9843(10)	0.2819(6)	0.094(9)			
C(5)	-0.0683(13)	0.7733(7)	0.0324(5)	0.046(7)			
C(6)	0.1694(11)	0.8861(7)	0.0334(5)	0.033(6)			
C(7)	0.1291(11)	0.9041(7)	-0.0275(5)	0.034(6)			
C(8)	0.2062(13)	0.9523(8)	-0.0675(5)	0.052(8)			
C(9)	0.3309(15)	0.9824(8)	-0.0478(6)	0.061(8)			
C(10)	0.3817(12)	0.9618(8)	0.0122(6)	0.051(8)			
C(11)	0.3034(12)	0.9149(7)	0.0521(5)	0.043(7)			
C(12)	0.1710(11)	0.7276(6)	0.1128(4)	0.027(5)			
C(13)	0.2936(12)	0.7323(7)	0.1461(5)	0.046(7)			
C(14)	0.3734(13)	0.6641(8)	0.1595(6)	0.051(8)			
C(15)	0.3296(13)	0.5871(7)	0.1420(5)	0.051(7)			
C(16)	0.2115(13)	0.5788(7)	0.1083(5)	0.046(7)			
C(17)	0.1332(11)	0.6478(7)	0.0950(5)	0.037(6)			
C(18)	0.0871(16)	0.7746(8)	0.2750(5)	0.065(8)			
C(19)	-0.2320(15)	0.8523(9)	0.2734(7)	0.087(9)			
C(20)	-0.1659(14)	0.7044(8)	0.1888(6)	0.058(8)			
C(21)	-0.3400(12)	0.8563(10)	0.1203(7)	0.072(9)			
C(22)	-0.1520(13)	0.9942(8)	0.0465(5)	0.057(8)			
C(23)	-0.2237(16)	1.0347(9)	0.1826(6)	0.086(9)			
C(1s)	0.0271(20)	0.2612(16)	0.9839(8)	0.139(16)			
C(2s)	0.1184(24)	0.1960(13)	0.9583(11)	0.194(19)			
C(3s)	0.0771(24)	0.1692(9)	0.8912(10)	0.141(15)			
C(4s)	0.0727(22)	0.2358(17)	0.8487(14)	0.280(22)			
C(5s)	-0.0186(24)	0.2851(14)	0.8629(11)	0.188(20)			
C(6s)	0.0006(25)	0.3252(12)	0.9342(8)	0.151(17)			
C(7s)	0.0751(31)	0.2990(17)	1.0391(8)	0.207(23)			
Si(2a)	-0.1928(8)	0.8214(5)	0.1774(4)	0.045(4)			
Si(3a)	-0.0721(9)	0.9905(5)	0.1287(4)	0.044(4)			
Si(4a)	0.0812(9)	0.8813(5)	0.2285(3)	0.048(4)			

^a U_{eq} is defined as one third of the trace of the orthogonalised U_{ij} tensor.

For Si(2), Si(3), and Si(4) the occupancy is 0.55. For Si(2a), Si(3a), and Si(4a) the occupancy is 0.45.

1.27 Å, *d*(C–N) 1.14 Å, C–O–C 118.3°, O–C–N 173.5° [15].

3. Experimental details

3.1. Compound 4

Crystallization of 4 [7] from hexane gave crystals suitable for the diffraction study. A crystal of dimensions $0.18 \times 0.30 \times 0.18$ mm³ was used for the data collection.

Crystal data. $C_{28}H_{39}ONSi_4$: M = 518.0, orthorhombic, space group *Pbca*, a = 11.160(3), b = 17.766(2), c = 29.602(7) Å, U = 5868.8 Å³, Z = 8, $D_c = 1.2$ g cm⁻³, F(000) = 2224, Mo-K α radiation, $\lambda = 0.71069$ Å, $\mu = 2.2$ cm⁻¹.

Data were collected at room temperature on an Enraf-Nonius CAD4 diffractometer. Intensities of 5737 unique reflections with +h + k + l and $2 < \theta < 25^{\circ}$ were measured by a $\theta/2\theta$ scan with width $\theta = (0.8 + 0.35 \tan \theta)^{\circ}$ and a maximum scan time of 1 min. There was no decay during the data collection. Corrections were made for Lorentz and polarization effects. A total of 2582 unique reflections with $|F^2| > 2\sigma(F^2)$ were used in the refinement, where $\sigma(F^2) = [\sigma^2(I) + (0.04I)^2]^{1/2}/L_{\rm p}$.

Direct methods were used to find the Si atoms and a difference map to find the C, O, and N atoms, and all these were refined by full matrix least squares with anisotropic temperature factors. The hydrogen atoms were placed in calculated positions with $U_{\rm iso} = 1.3U_{\rm eq}$ for the atoms to which they are attached. Refinement converged at R = 0.063, R' = 0.057 with weighting scheme $w = 1 | \sigma^2(F)$.

Atomic coordinates are listed in Table 4. A complete list of bond lengths and angles and tables of anisotropic thermal parameters and hydrogen atom coordinates have been deposited at the Cambridge Crystallographic Data Centre.

3.2. Compound 5

This compound was made as described previously [16] and recrystallized from methylcyclohexane as the monosolvate.

Details of the data collection and refinement are shown in Table 5. Two standard reflections monitored every hour showed a small increase in intensity and a correction was made for this. Refinement as the opposite absolute structure gave identical results. Atomic coordinates are listed in Table 6. A complete list of bond lengths and angles and tables of hydrogen atom coordinates and ansotropic thermal parameters have been deposited at the Cambridge Crystallographic Data Centre.

Acknowledgements

We thank the SERC for support of this work, the Ministry of Higher Education of Saudi Arabia for the award of a postgraduate scholarship to A.K.A. Al-N., and the University of Papua New Guinea for granting research leave to G.A.A.

References

- M.J. Barrow, S. Cradock, E.A.V. Ebsworth and M.M. Harding, J. Chem. Soc., Chem. Commun., (1977) 744.
- [2] A.I. Gusev, E.B. Chuklanova, A.S. Zhdanov, E.V. Muzovskaya and V.P. Kozyukov, Zh. Strukt. Khim., 30 (1989) 182.
- [3] E.B. Chuklanova, A.I. Gusev, A.S. Zhdanov, E.V. Muzovskaya and V.P. Kozyukov, Organomet. Chem. USSR, 1 (1988) 629.
- [4] M. Fehér, T. Pasinszki and T. Veszprémi, J. Phys. Chem., 97 (1993) 1538.
- [5] J.A. Duckett, A.G. Robiette and M.C.L. Gerry, J. Mol. Spectrosc., 90 (1981) 374.
- [6] C. Eaborn, P.D. Lickiss, G. Marquina-Chidsey and E.Y. Thorli, J. Chem. Soc., Chem. Commun., (1982) 1326 (see also Ref. [7]).
- [7] C. Eaborn, Y.Y. El-Kaddar and P.D. Lickiss, *Inorg. Chim Acta*, 198-200 (1992) 337.
- [8] G. Glidewell, A.G. Robiette and I.M. Mills, Chem. Phys. Lett., 16 (1972) 526.
- [9] A.G. Avent, S.G. Bott, J.A. Ladd, P.D. Lickiss and A. Pidcock, J. Organomet. Chem., 427 (1992) 9.
- [10] S.S. Al-Juaid, C. Eaborn, A. Habtemariam, P.B. Hitchcock, J.D. Smith, K. Tavakkoli and A.D. Webb, J. Organomet. Chem., 462 (1993), 45.
- [11] S.S. Al-Juaid, S.M. Dhaher, C. Eaborn, A. Habtemariam, P.B. Hitchcock and J.D. Smith, J. Organomet. Chem., 325 (1987) 117.
- [12] C. Eaborn, P.B. Hitchcock and P.D. Lickiss, J. Organomet. Chem., 269 (1984) 235.
- [13] S.S. Al-Juaid, C. Eaborn, P.B. Hitchcock, P.D. Lickiss, J.D. Smith, K. Tavakkoli and A.D. Webb, to be published.
- [14] See for example, N.B. Buttrus, C. Eaborn, P.B. Hitchcock, P.D. Lickiss and S.T. Najim, J. Chem. Soc., Perkin Trans., 2 (1987) 891.
- [15] L. Kutshabsky and H. Schrauber, Z. Chem., 11 (1971) 347; Krist. Tech., 8 (1973) 217.
- [16] C. Eaborn and A.I. Mansour, J. Chem. Soc., Perkin Trans., 2 (1985) 729.